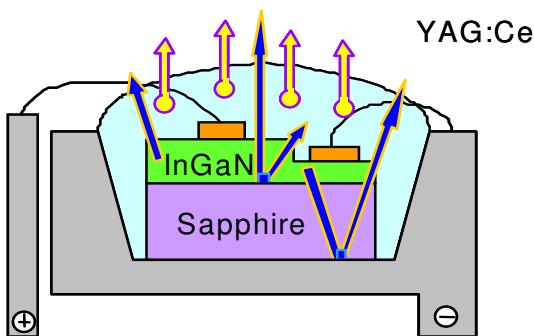


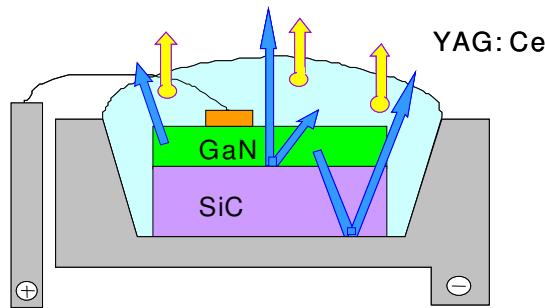
# White LED 시판 품

상용화된 White를 만드는 3가지 방법  
→ Sumitomo 방식 white 조사

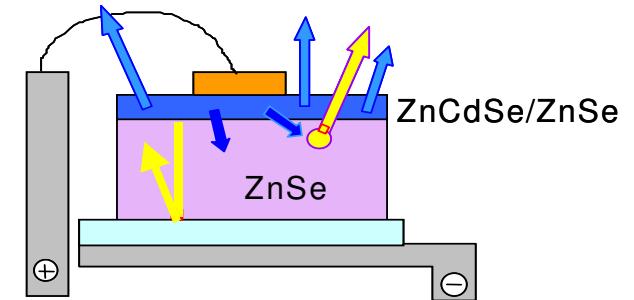
Nichia



Osram



Sumitomo



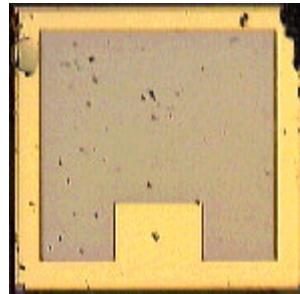
- 청색 InGaN LED + 황색 YAG:Ce
- 발광 효율: 15 lm / W

- SiC-base 청색 InGaN LED + 황색 YAG :Ce
- Particle size<20 $\mu\text{m}$
- 발광 효율: 10 lm / W

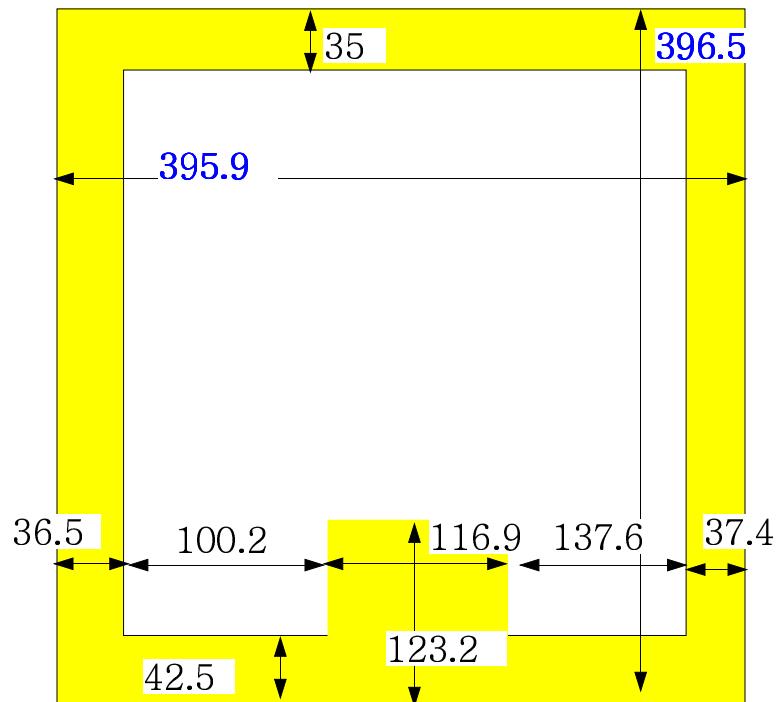
- ZnCdSe/ZnSe 활성층의 청색 + ZnSe 기판에서 나오는 황색 PL
- 도전성 ZnSe 사용하여 소자 구동전압 감소: 2.7 V  
→ 휴대폰용 back light에 적합
- 발광 효율 : 8 lm / W

# Sumitomo ZnCdSe White

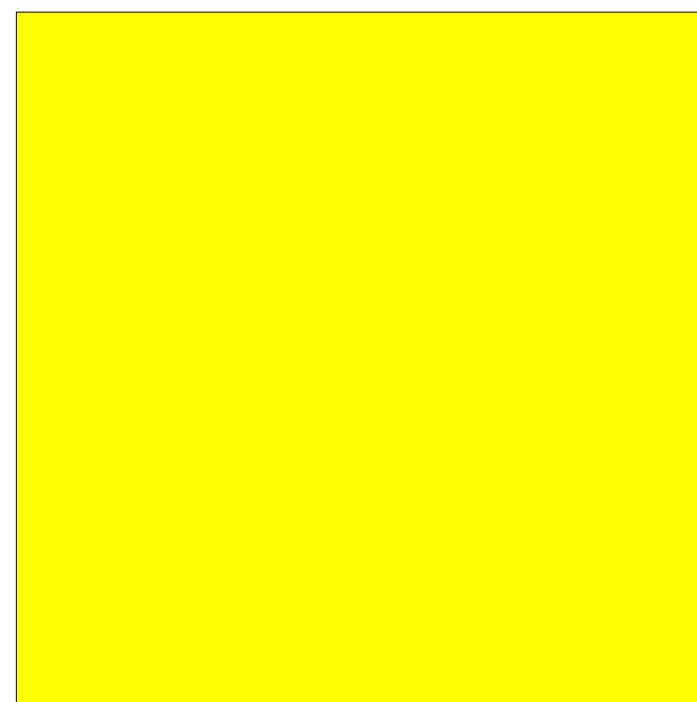
1. chip size 측정



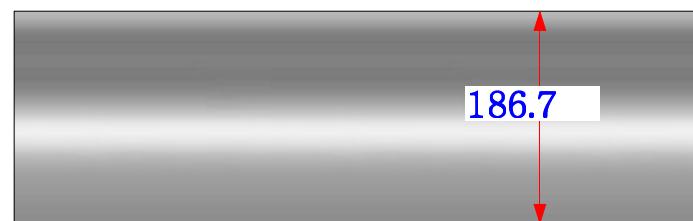
p font side

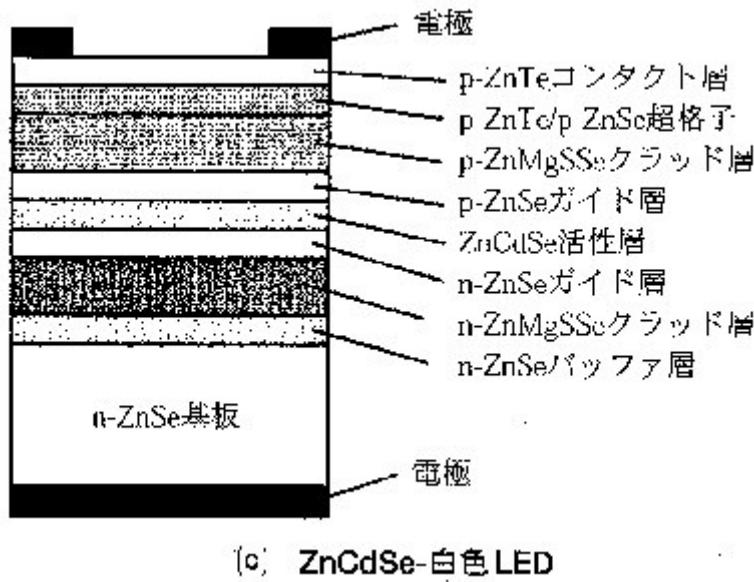


n back side

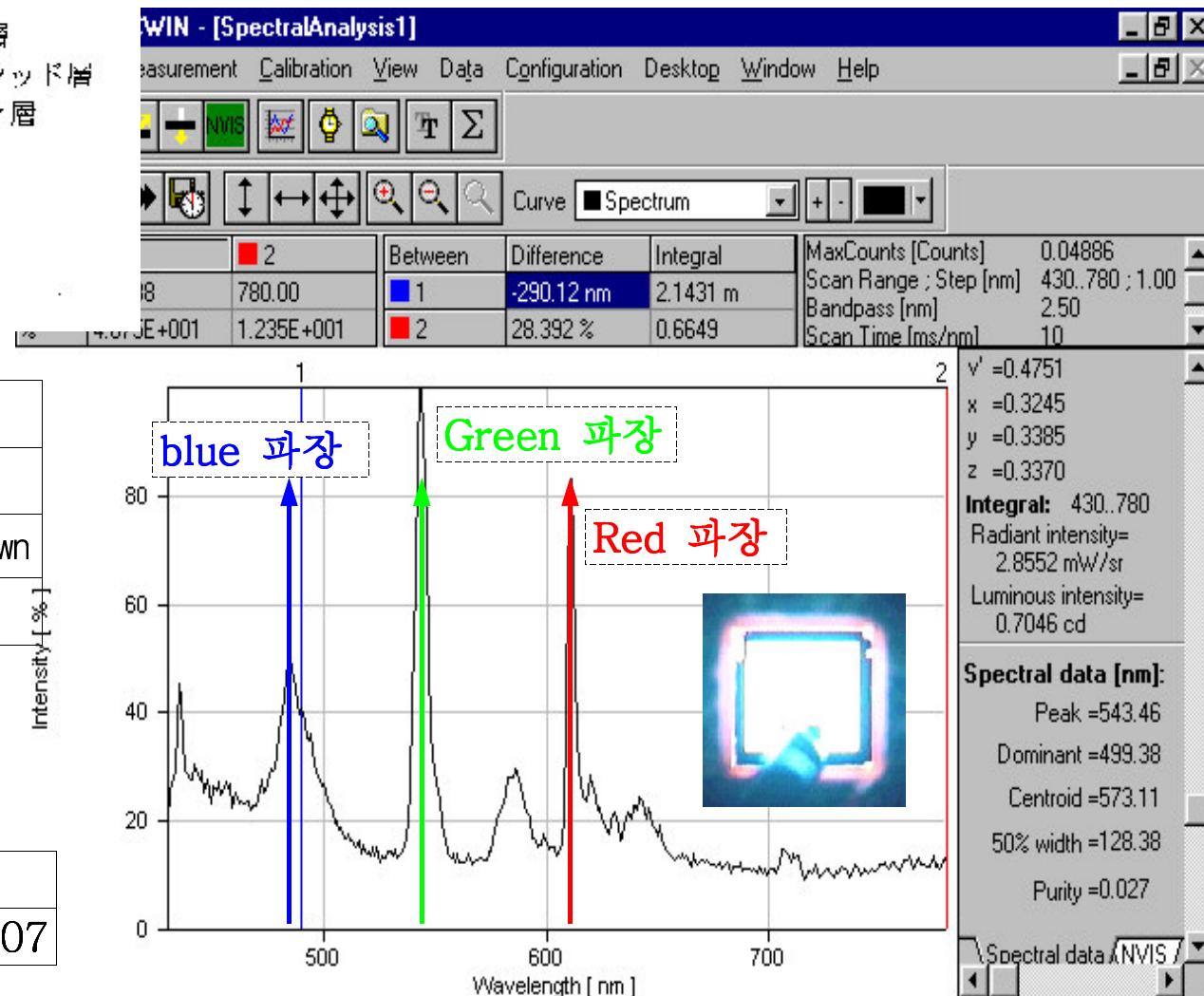


측면





## 2. Spectrum analyzer 측정



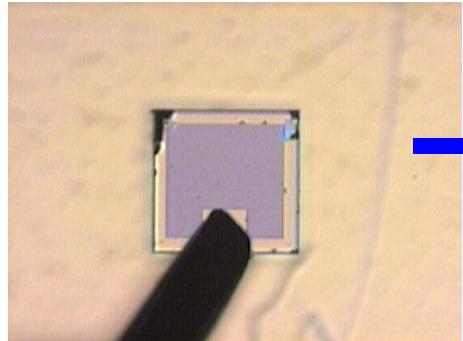
	bias	비고
Vf (@ 10uA)	2.07 V	
Vr (@-10uA)	-44 V	hard breakdown
Vf (@ 5mA)	2.45 V	

u'	v'	x	y	z
0.202	0.4774	0.3268	0.3425	0.3307

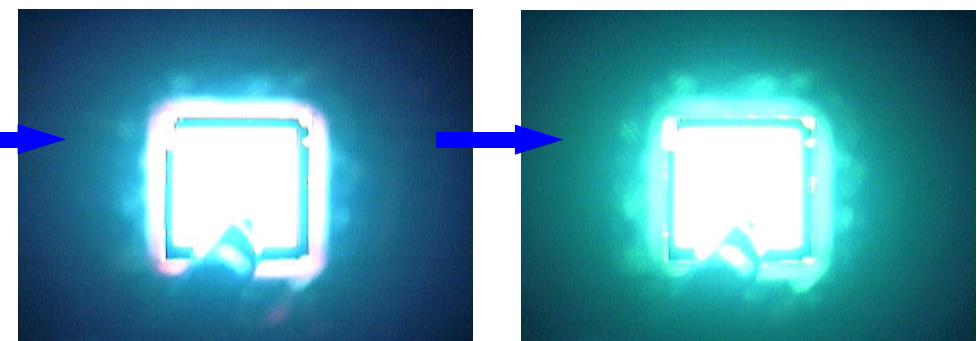
### 3. 발광 사진

x50

without current



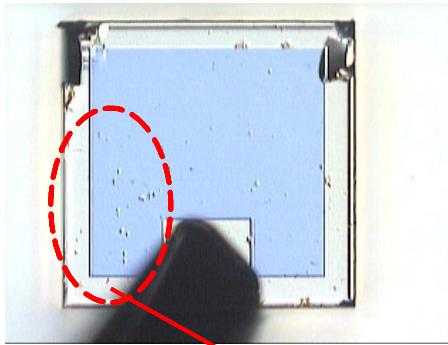
with current → 점차적으로 전류를 증가 시킴.



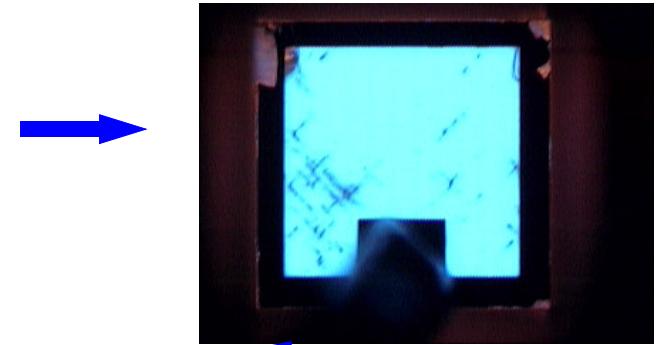
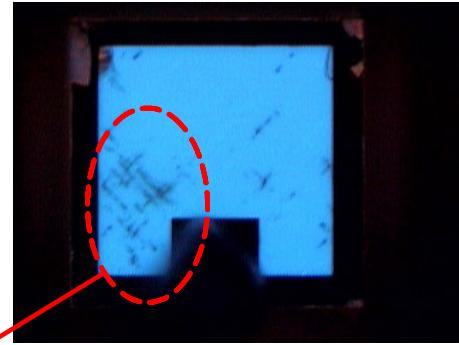
#### 4. 발광 사진 x100

p-wire bonding 면

[without current]

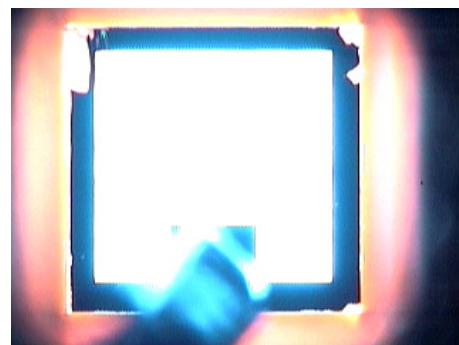
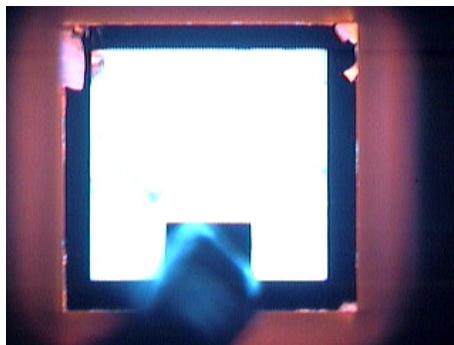


[with current → 점차적으로 전류를 증가 시킴.]



[발광시 defect로 작용하여 비 발광 함.]

[low current에서는 청색 발광만 함.]

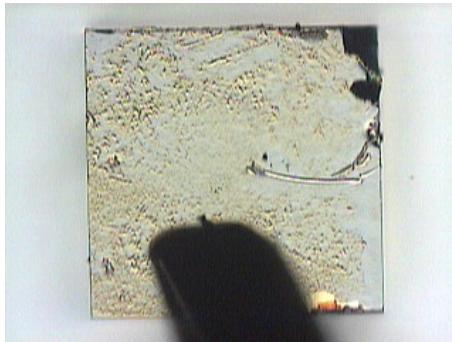


[current가 증가함에 따라서 ZnSe 기판에 여기한  
Yellow PL과 함께 white가 나옴]

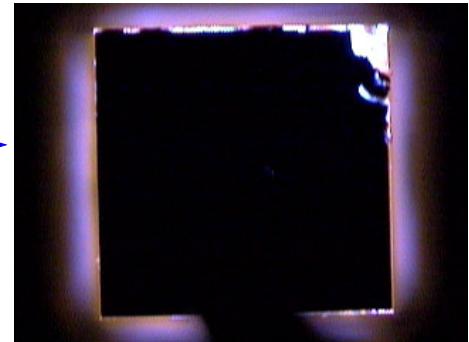
## 5. 발광 사진 x100

n-die면

without current

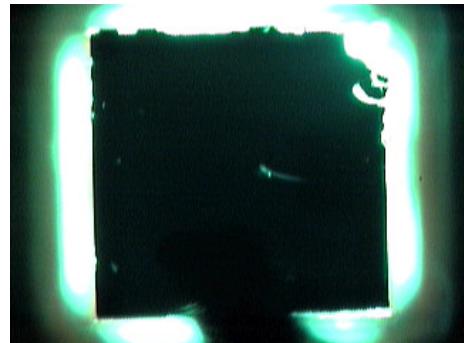
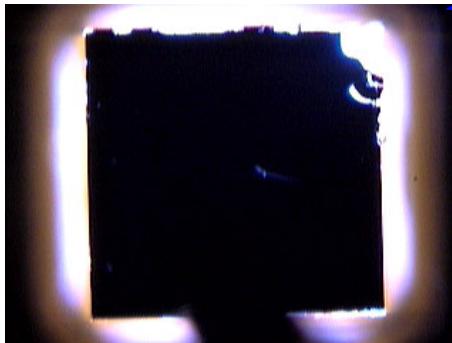


with current → 점차적으로 전류를 증가 시킴.

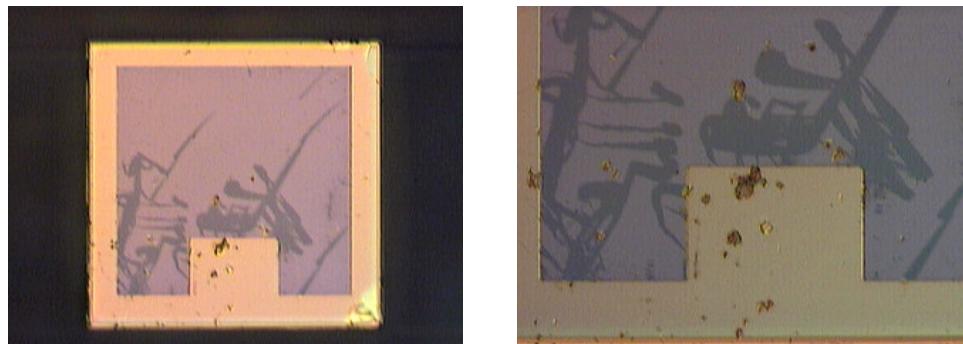
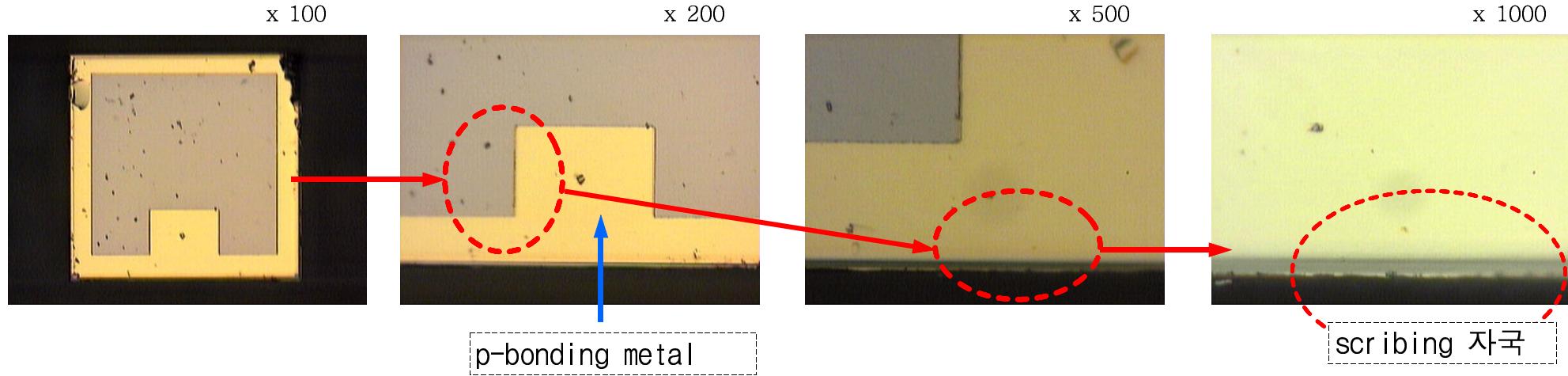


n-die bonding면 쪽에서 발광모양을 관찰함.

→ n-side contact metal이 전면 증착되어 있으므로 측면에서만 발광을 관찰 할 수 있음

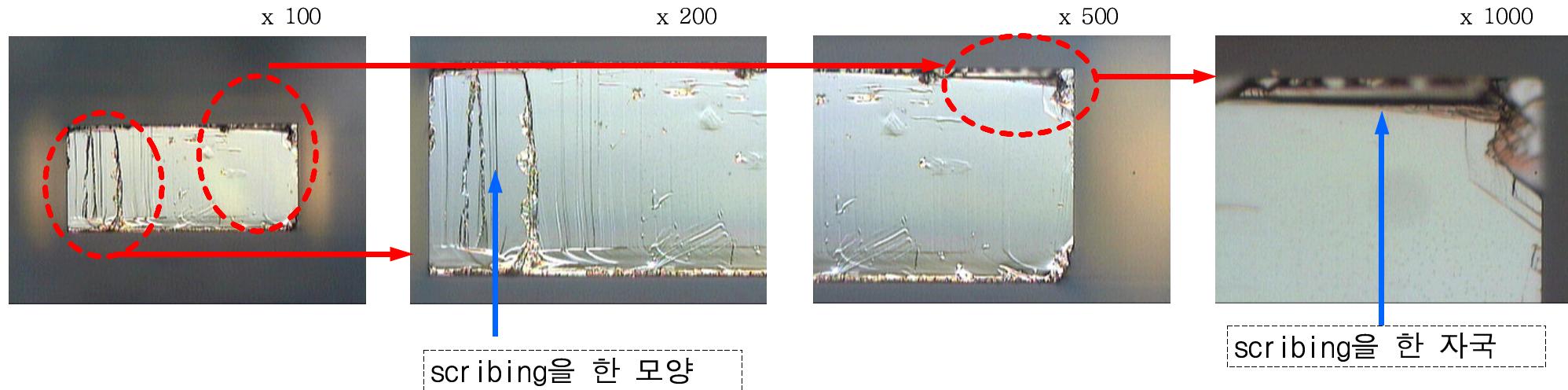


## 6.p-front side



Semi-transparent metal에  
scratch가 있는 모양

## 7. 측면



## 8. n-side

